

PATENT YOR920040022 IBM-272

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Matthew Colburn, et al.

Serial Number : 10/799,282

Filing Date : March 13, 2004

Examiner : John A. McPherson

Group Art Unit : 1756

For : Method for Fabricating Dual Damascene Structures

Using Photo-Imprint Lithography, Methods for Fabricating Imprint Lithography Molds for Dual Damascene Structures, Materials for Imprintable Dielectrics and Equipment for Photo-Imprint Lithography Used in Dual Damascene Patterning.

TO: The Honorable Commissioner of Patents and Trademarks Post Office Box 1450 Alexandria, VA 22313-1450

CHANGE OF ADDRESS

Please address all future correspondence in this matter to the undersigned at 6136 West Kimberly Way, Glendale, AZ 85308.

Respectfully Submitted,

homas A. Beck

Registration No. 20,816

6136 West Kimberly Way

Glendale, AZ 85308

Telephone (623) 466-0080

I hereby certify that this paper is being transmitted by First Class mail addressed to Commissioner of Patents & Trademarks, Post Office Box 1450, Alexandria, VA 22313-1450.

Signature:

Name:

homas A. Beck

Date: June 30, 2007